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Recent Advances in BiVO_4 - and Bi_2Te_3 -Based Materials for High Efficiency-Energy Applications

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Abstract

This chapter provides recent progress in developments of BiVO_4 - and Bi_2Te_3 -based materials for high efficiency photoelectrodes and thermoelectric applications. The self-assembling nanostructured BiVO_4 -based materials and their heterostructures (e.g., $\text{WO}_3/\text{BiVO}_4$) are developed and studied toward high efficiency photoelectrochemical (PEC) water splitting via engineering the crystal and band structures and charge transfer processes across the heterojunctions. In addition, crystal and electronic structures, optical properties, and strategies to enhance photoelectrochemical properties of BiVO_4 are presented. The nanocrystalline, nanostructured Bi_2Te_3 -based thin films with controlled structure, and morphology for enhanced thermoelectric properties are also reported and discussed in details. We demonstrate that BiVO_4 -based materials and Bi_2Te_3 -based thin films play significant roles for the developing renewable energy.

Keywords: BiVO_4 , bismuth telluride (Bi_2Te_3), photoelectrochemical (PEC) water splitting, thermoelectrics, pulsed laser deposition

1. Bismuth vanadate (BiVO_4) material: a highly promising photoanode for use in solar water oxidation

The photoelectrochemical (PEC) water splitting, which uses semiconductors to directly harvest and convert the abundant solar energy into storable and friendly environmental energy in the form of hydrogen and oxygen from water, has been regarded as a promising approach to solve our current energy challenges [1–6]. The PEC cell for energy conversion on a global scale requires the development of devices that are highly efficient, stable, and simple in design. The effective

and economic energy transfer technologies are still under developing stage for more than 40 years. The PEC water splitting becomes more competitive as the cost continues to decrease with the development of nanotechnology, which offers the use of new nano-heterostructure photocatalysts. The current direction along this research field focuses on the development of high efficiency photoelectrodes based on metal oxides due to their high chemical and photostability, low cost, and ease of fabrication. Among these interesting and important photoelectrode materials for PEC, BiVO_4 is demonstrated as a promising photocatalyst for PEC water splitting. Originally, the BiVO_4 was intensively studied as a ferroelasticity, acoustic-optical, and ionic conductivity materials [7]; however, recently most studies focus on its photocatalytic activity owing to its direct bandgap of ~ 2.5 eV together with the desirable band edges and good stability [8–11]. Additionally, the theoretical solar-to-hydrogen conversion efficiency of the monoclinic BiVO_4 could reach 9.2% with a maximum photocurrent of 7.5 mA cm^{-2} under standard AM 1.5 solar light irradiation, which is significantly higher than those of the common metal oxides, and thus the monoclinic BiVO_4 has been recognized as one of the most promising photoanode materials for PEC water splitting [1]. However, its photoactivity performance is limited by its poor electrical conductivity, slow hole transfer kinetics for water oxidation, and poor charge separation [12]. A concise overview of BiVO_4 electronic and optical properties as well as the alternative strategies to improve its photocatalytic activities is discussed in this section.

2. Crystal and electronic structures of bismuth vanadate

The synthesis BiVO_4 crystallizes in three main crystal structures of tetragonal scheelite, monoclinic phase, and tetragonal zircon structure. The photocatalytic activities of BiVO_4 strongly depend on the optical properties of each crystal structure. Among these structures, the monoclinic scheelite BiVO_4 was demonstrated to exhibit the highest photocatalytic water oxidation under visible light illumination [13]. The higher photocatalytic activity of the monoclinic scheelite was attributed to its smaller energy band gap and higher crystal distortion, which enhance the optical absorption and the electron-hole separation [14]. The conduction-band minimum of BiVO_4 is formed mainly by V 3d, which splits into triplet bands V 3d x^2-y^2/z^2 , V 3d z^2/zx , and V 3d zy/xy [15]. The valence band (VB) of tetragonal zircon structure BiVO_4 is formed by O 2p orbital, but the top region of VB of monoclinic structure is formed by both Bi 6 s and O 2p orbitals. It was demonstrated that Bi 6 s is located above O 2p and the smaller bandgap of monoclinic BiVO_4 attributes to the transition from the 6 s electrons of Bi to the 3d orbital of V [14, 16]. Recently, Zou et al. demonstrated that the crystal distortion in monoclinic BiVO_4 improves the lone-pair impact of Bi 6 s states which raises up the O 2p states and reduces the bandgap [17]. In addition, the monoclinic scheelite structure possesses the better electron-hole separation owing to its higher degree of structural distortion than that in the tetragonal scheelite structure to result in enhanced photocatalytic activity for the monoclinic structure. In addition, the conduction-band edge of BiVO_4 is only slightly below the H^+/H_2 redox potential, while its valence band is much below the oxidation potential of water resulting in low required external bias [15].

In order to investigate the experimental crystal and electronic structure of monoclinic BiVO_4 , the single crystal BiVO_4 , which possesses good crystallinity and eliminates the structural and electronic defects as well as impurity phases, is required. The vacuum deposition such as

sputtering, molecular beam epitaxy, and pulsed laser deposition for the single crystal monoclinic BiVO_4 has been developed recently [18–20]. A good lattice match (mismatch less than 1%) of cubic yttrium-stabilized zirconia (YSZ, $a = 5.145 \text{ \AA}$) was used as substrate for epitaxial growth of high-quality epitaxial monoclinic BiVO_4 ($a = 5.1935 \text{ \AA}$, $b = 5.0898 \text{ \AA}$, $c = 11.6972$, $\gamma = 90.3871$) films. The X-ray diffraction θ - 2θ scan (**Figure 1a**) shows only high intensity and sharp (00 l) reflections of monoclinic BiVO_4 phase indicating that growth was c -axis oriented: BiVO_4 (001) || YSZ (001). The high-resolution TEM image (the inset of **Figure 1**) reveals the

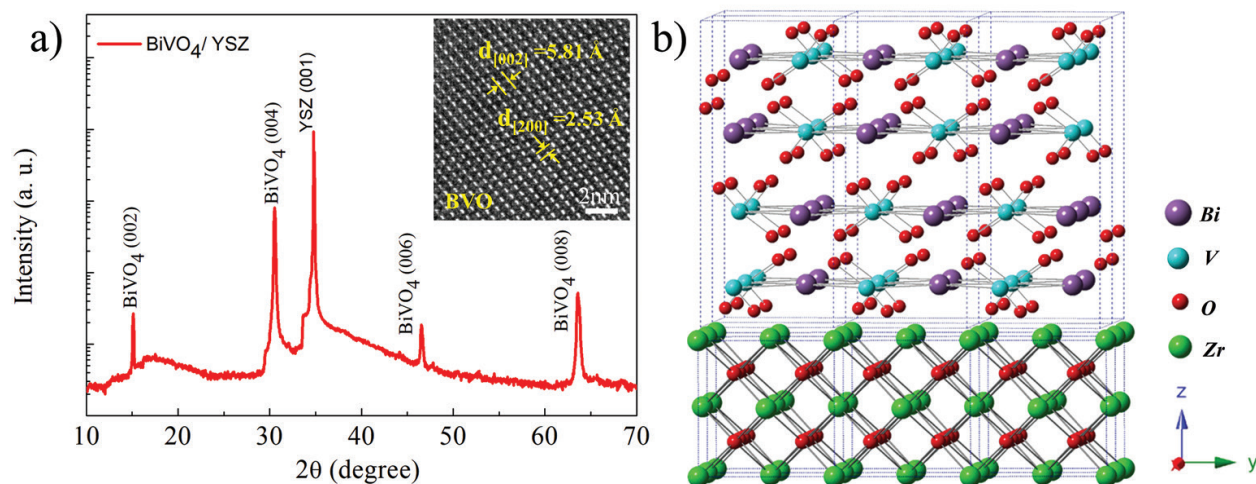


Figure 1. (a) XRD $2\theta/\theta$ scans of BiVO_4 film grown on YSZ substrate, and the inset shows HR-TEM image of BiVO_4 ; (b) atomic model of BiVO_4/YSZ heterojunction.

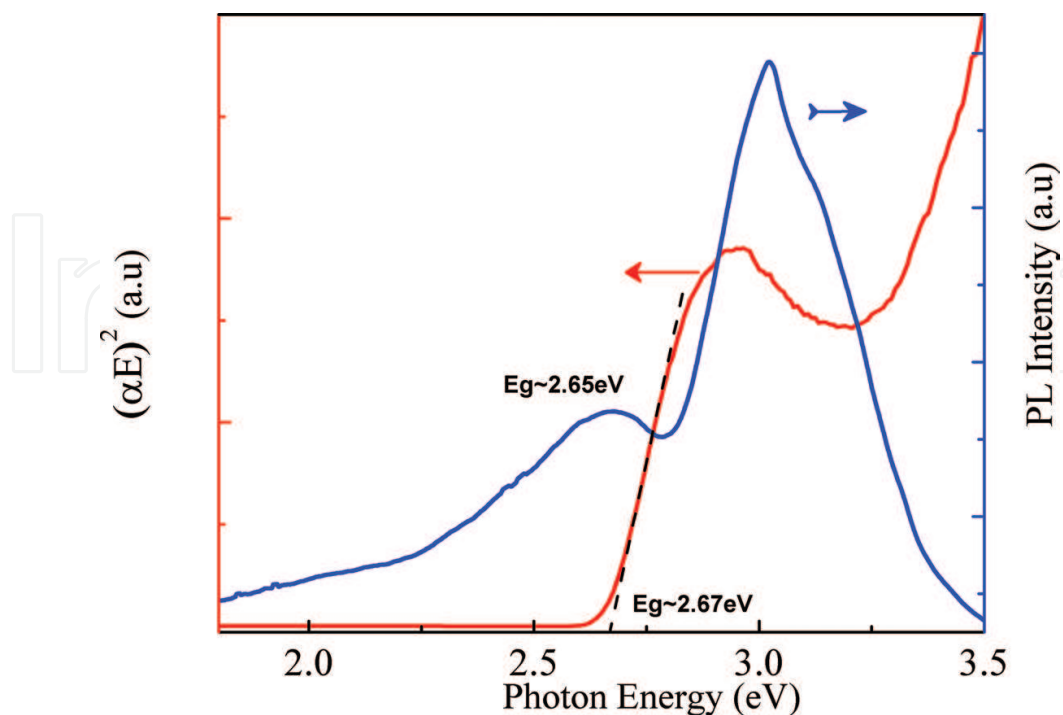


Figure 2. Photoluminescence taken under the irradiation of 325 nm laser at room temperature (green curve) and UV-Vis absorption spectrum (red curve) of BiVO_4 epitaxial film.

in-plane and out-of-plane lattice parameters of the BiVO_4 with $d_{200} = 2.53 \text{ \AA}$ and $d_{002} = 5.81 \text{ \AA}$ which are in good agreement with the lattice constants of the bulk monoclinic BiVO_4 . The orientation and growth direction of BiVO_4 crystal were identified and constructed in the corresponding atomic model as shown in **Figure 1b**.

The electronic structural properties of single crystal BiVO_4 were investigated by the photoluminescence (PL) spectroscopy and UV-Visible spectroscopy. **Figure 2** presents the PL and UV-Vis absorption spectra of a single crystal BiVO_4 film. As presented in the UV-Vis absorption spectrum, the observed absorption in the range of 440–480 nm corresponding to the bandgap of $\sim 2.67 \text{ eV}$ could attribute to the transition from the 6 s electrons of Bi (or the hybrid orbital of Bi 6 s and O 2p) to the empty 3d x^2-y^2/z^2 orbital of V, which is consistent with emission peak of 2.65 eV in the PL spectrum. The second absorption band edge of approximately 3.15 eV and the second PL emission peak at 3.1 eV could be ascribed to the electron transition from O 2p valence band to V 3d z^2/zx and/ or V 3d zy/xy orbitals.

3. Strategies to enhance photoelectrochemical properties of BiVO_4

The development of suitable techniques to fabricate high efficiency BiVO_4 photoelectrode for PEC water splitting is crucial. To date, there are many methods, which have been developed to prepare BiVO_4 photoelectrodes for use in solar water oxidation. The representative synthesis methods are (1) metal organic decomposition (MOD) combining with the spin coating or spray pyrolysis deposition [21–23], (2) electrophoretic deposition (EPD) and chemical bath deposition (CBD) [24–27], and (3) vacuum deposition methods such as sputtering deposition and pulsed laser deposition (PLD) [18–20, 28–29]. The MOD is a facile method to synthesize BiVO_4 materials for photoelectrodes. The main advantages of the MOD method are the easy composition tuning and morphology engineering. However, the existence of crystal and surface defect and low adhesion between BiVO_4 and conducting substrate could limit its performance. The EPD and CBD methods are simple, have low cost, and are easy to scale up. The vacuum deposition is a powerful method to synthesize good crystalline BiVO_4 photoelectrodes. The samples prepared by this method could easily control the doped composition; could facilitate tune the crystalline in form of amorphous, polycrystalline, and single crystalline; and possess a good adhesion.

As described above, BiVO_4 has many advantages features, however, the actual PEC performance of undoped BiVO_4 is still far below its theoretical value, indicating that its advantages have not been fully developed. Many research groups have improved photoelectrochemical water oxidation by the introduction of (1) controlled morphologies, (2) forming nanocomposite structure, (3) doping, and (4) decorating with cocatalysts [30]. A summary of advantages and alternative strategies to enhance photoelectrochemical properties of BiVO_4 was depicted in **Figure 3**. The best PEC performance of BiVO_4 photoelectrodes that has been demonstrated to date is a combination of several above strategies to take advantages of high surface area, high electron mobility, high water oxidation kinetics, and low charge carrier recombination. Therefore, understanding the benefits and disadvantages of each strategy could provide an effective way to enhance the PEC properties.

First, the morphologies of BiVO_4 photoelectrode such as shape, size, and particle contact strongly effect on their interfacial energetics, kinetics, and charge transport properties as well as reactive sites. Because the electrochemical reactions only occur at the electrode-electrolyte interfacial area, the photogenerated electron-hole needs to be transferred to the surface for the reactions. Thus, the development of high surface area photoelectrodes is necessary. The porous structure and one-dimensional nanostructure such as nanorod/nanowire arrays reveal high surface areas per electrode volume, which directly improves the PEC efficiency. The high efficient PEC devices based on the BiVO_4 porous structure and the one-dimensional nanostructures have been reported by many research groups [31–34]. However, creating more porosity or smaller nanorod/nanowire structures to improve surface area could increase the defect site, increase grain boundaries, and reduce crystallinity leading reduction photocatalytic activity [35]. In addition, with hole diffusion length of ~ 100 nm and carrier mobility of $0.044 \text{ cm}^2 \text{ V}^{-2} \text{ s}^{-1}$ [36], the length and thickness of nanostructure should be finely optimized to maximum light absorption and photogenerated charge carrier transport. Furthermore, researchers have recently demonstrated that the charge separation and photoactivity properties are closely related to the exposed crystal facet of BiVO_4 photocatalysts [8–9, 37–39]. Therefore, an optimized design and morphological control of crystal facets could improve the PEC performance.

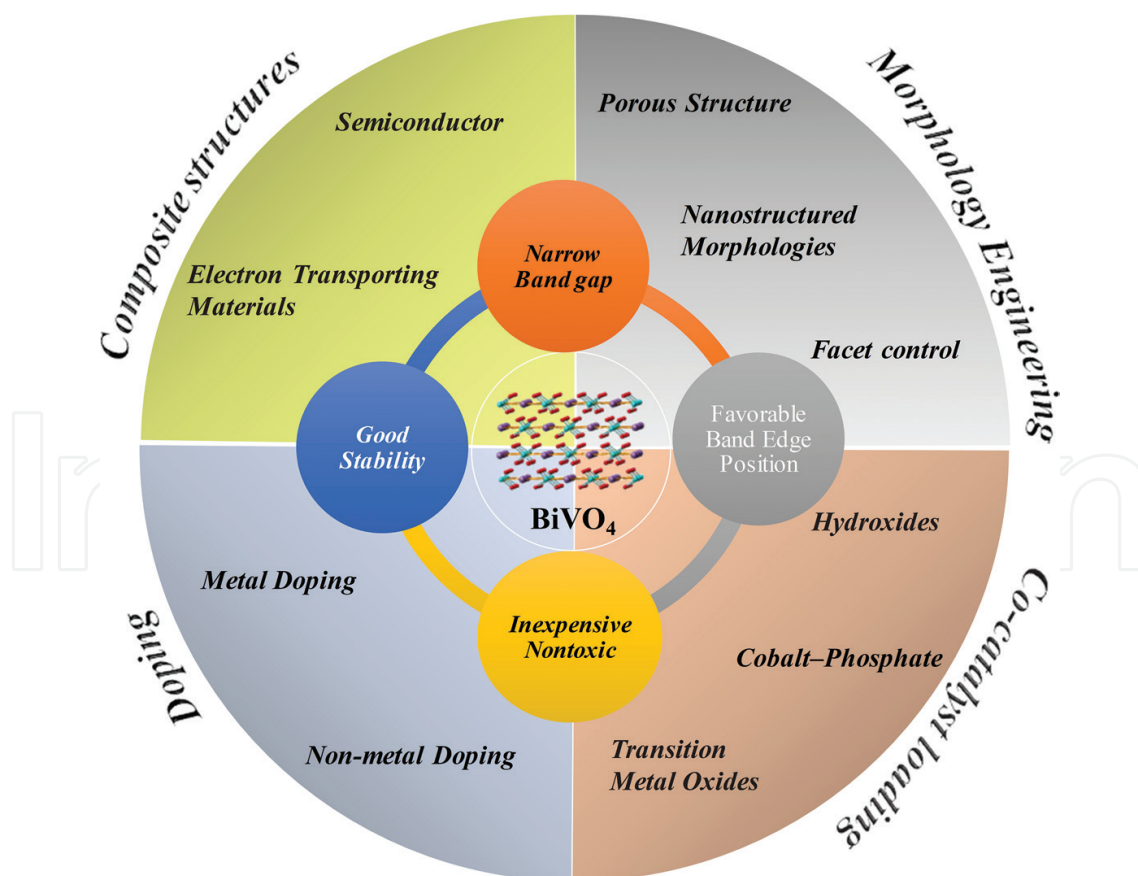


Figure 3. The advantages and strategies to enhance photoelectrochemical properties of BiVO_4 .

Second, nanocomposites provide a powerful route to overcome limitations in the current studies of single material systems for water splitting, where the photoelectrochemical performance of photoelectrode can be significantly improved by the choice of proper interactions of constituents. The construction of nanocomposite consisting of BiVO_4 and addition semiconductor/or conductor can improve the optical absorption, charge carrier separation, and charge transport processes. Combination of BiVO_4 with additional metal oxide semiconductors could enhance overall photon absorption and improve electron-hole separation by the rapid photogenerated electron and hole injections at their heterojunctions and extension the optical absorption range. Many BiVO_4 -based heterostructures have been fabricated successfully such as $\text{TiO}_2/\text{BiVO}_4$, $\text{Ag}_3\text{PO}_4/\text{BiVO}_4$, $\text{Bi}_2\text{S}_3/\text{BiVO}_4$, $\text{g-C}_3\text{N}_4/\text{BiVO}_4$, $\text{BiVO}_4/\text{SnO}_2$, $\text{WO}_3/\text{BiVO}_4$, $\text{BiOCl}/\text{BiVO}_4$, $\text{Fe}_2\text{O}_3/\text{BiVO}_4$, $\text{Cu}_2\text{O}/\text{BiVO}_4$, and ZnO/BiVO_4 [40–43]. Among them, the WO_3 is a commonly coupled semiconductor with BiVO_4 because it is a stable n-type semiconductor with better electron transport properties than the BiVO_4 and a suitable conduction-band edge for facile electron injection from conduction band of BiVO_4 [29, 44–46].

Recently, we reported a self-assembled nanocomposite photoanode composed of epitaxial BiVO_4 matrix embedded with WO_3 mesocrystal for photoelectrochemical application in the visible light regime using PLD [29]. By taking the advantage of the structural feature of this heterostructure, the well-defined crystal facet and interface between WO_3 and BiVO_4 phases provide a template for the fundamental understanding of photoactivity in the nanocomposite. The BiVO_4 - WO_3 crystal structure details were investigated by XRD and TEM as shown in **Figure 4**. The XRD 2θ - θ scans, in-plane Φ -scans, and reciprocal space map results clearly show that BiVO_4 and WO_3 spontaneously separated into two single phases during the deposition with an in-plane orientation relationship as $[100]_{\text{BiVO}_4} // [110]_{\text{WO}_3} // [001]_{\text{YSZ}}$. Both monoclinic BiVO_4 and orthorhombic WO_3 phases exhibit two sets of structural domains, which are separated by a 90° rotation around c -axis. The microstructure and the epitaxial relationship of BiVO_4 - WO_3 heterostructure were further investigated as displayed in **Figure 4(b–e)**, which are in an excellent agreement with the XRD analyses. The self-assembled mesocrystal-embedded heterostructure that composed WO_3 and BiVO_4 phases is illustrated in **Figure 4g**. The energy band alignment of BiVO_4 - WO_3 heterojunction illustrated using X-ray photoelectron spectroscopy technique shows that the valence band maxima of WO_3 lies 0.55 eV below that of BiVO_4 and the conduction-band minimum of WO_3 lies 0.25 eV below that of BiVO_4 . This energy band structure could favor the enhancement of photogenerated charge carrier separation, which was further confirmed by photoluminescence and ultrafast transient absorption spectroscopies. **Figure 5** shows Nyquist electrochemical impedance spectroscopy and Mott-Schottky analysis for the BiVO_4 - WO_3 photoelectrodes. The results demonstrated a much higher electron conductivity of WO_3 with carrier densities of $9.68 \times 10^{18} \text{ cm}^{-3}$ under light illumination than BiVO_4 . Therefore, the BiVO_4 matrix serves as the light absorber due to its narrow band-gap, and the WO_3 mesocrystal acts as an electron conductor owing to its high electron conductivity resulting in a significantly enhanced photoelectrochemical performance.

Further example could be observed in the double-deck inverse opal $\text{WO}_3/\text{BiVO}_4$ structure that could reach a photocurrent density of 3.3 mA/cm^2 at 1.23 V versus RHE and the core-shell $\text{WO}_3/\text{BiVO}_4$ helix nanostructure, in which BiVO_4 was doped with Mo and naturally doped with W from the WO_3 core, exhibits a high photocurrent density of 3.6 mA/cm^2 at 1.23 V versus RHE [34, 47]. More recently, the highest photocurrent density of 6.72 mA/cm^2 at 1.23 V versus RHE for

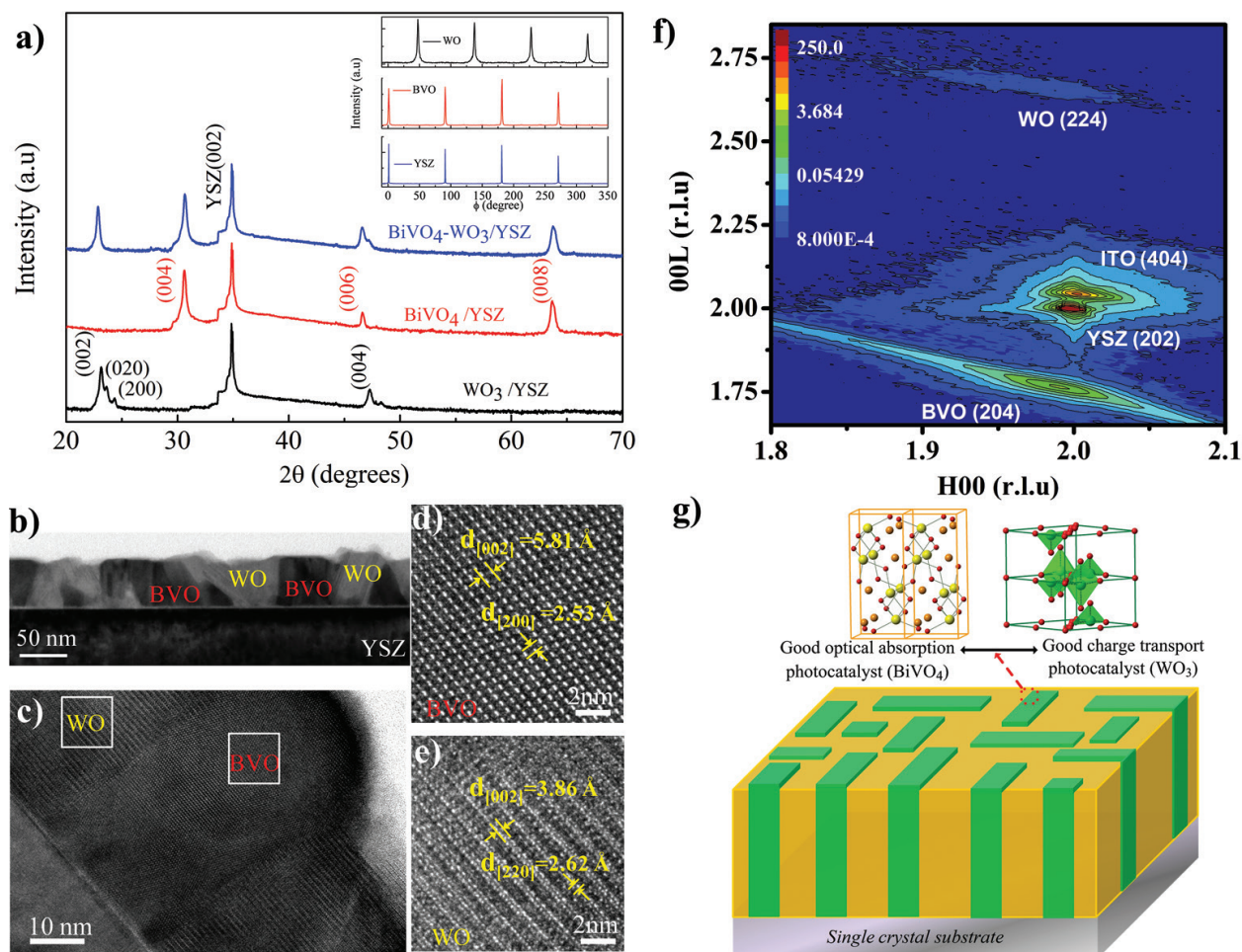


Figure 4. Structure characterization of BiVO_4 - WO_3 nanocomposite. (a) X-ray diffraction 2θ - θ scans of pure WO_3 , BiVO_4 , and the BiVO_4 - WO_3 nanocomposite showing only (00 l) type peaks of BiVO_4 and WO_3 . Inset shows XRD ϕ -scans of YSZ (220), BiVO_4 {013}, and WO_3 {022} reflections for BiVO_4 - WO_3 heterostructure. (b-e) Cross-sectional TEM images of BiVO_4 - WO_3 (BVO-WO) nanocomposite taken along $[010]_{\text{YSZ}}$ zone axis. The enlarged images taken from the marked areas of (d) BiVO_4 and (e) WO_3 showing their out-of-plane and in-plane d-spacing parameters. (f) X-ray reciprocal space maps (RSMs) of the composite grown on ITO/YSZ. (g) Illustration of self-assembled BiVO_4 - WO_3 nanocomposite [29].

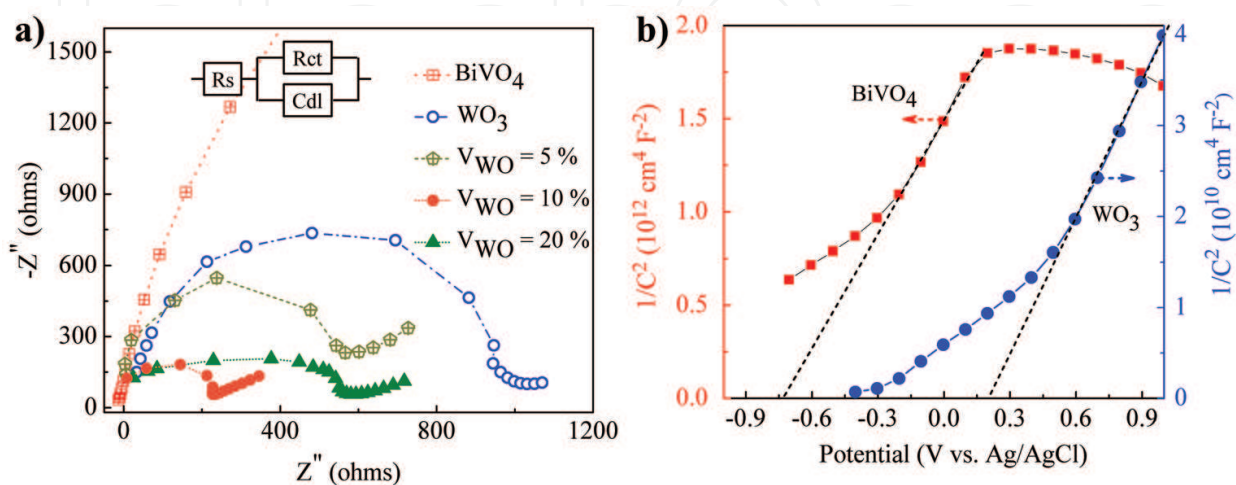


Figure 5. (a) The Nyquist plots and (b) the Mott-Schottky plots for the WO_3 , BiVO_4 , and BiVO_4 - WO_3 photoelectrodes in 0.5 M Na_2SO_4 solution under AM 1.5 illumination [29].

BiVO₄-based photoelectrode was obtained in the CoPi-coated WO₃/BiVO₄ core-shell nanorods [21]. The high efficiency photoelectrode was attributed to the superior charge carrier separation and efficient light scattering. In addition, by coupling with a conductor such as reduced graphene oxide and carbon nanotubes, the photocurrent density of the composite electrodes was improved significantly compared to those of the corresponding BiVO₄ electrodes which could attribute to the enhancement of charge separation and transport properties [49–57]. However, due to the low crystallinity of BiVO₄ as well as the poor BiVO₄-conductor and conductor-substrate contact in these nanocomposites, it needs to be further developed to improve the PEC performance.

Third, doping with the metal (such as W, Fe, B, Cu, Zn, Ti, Nb, Sn, Co, Pd, Rb, Ru, Ag, Ga, Sr, and Ir) or nonmetal (such as P and N) materials can change the electrical and optical properties of BiVO₄. Among them, only Mo- and W-doped BiVO₄ show a significantly enhanced photocurrent and IPCE [21]. The intentional introduction of n-type conductivity W and/or Mo atoms does not change the bandgap energy and band edge positions of doped-BiVO₄; however, it can increase the charge carrier density and the electrical conductivity. A suitable doping concentration of Mo and/or W results in significant improvement PEC performance of BiVO₄ [54–56]. On the other hand, P doping forms an internal electric field which may improve the photogenerated electron–hole separation. However, it is noted that the doping could induce trap carrier which can enhance charge carrier recombination and reduce the charge transport [35]. Therefore, the optimum doping concentration is a key factor to improve the overall PEC performance of the photoelectrode.

Finally, decoration of BiVO₄ with various oxygen evolution catalysts (OECs) such as Co–Pi, Co₃O₄, RhO₂, Pt, CoO, and FeOOH improves the kinetic for oxygen evolution and provides unique active sites for catalytic reactions, thereby strongly enhanced the photocurrent density [3, 27, 40, 57–58]. In addition, it decreases the bias potential and improves the stability of BiVO₄ photoanodes. Perhaps the most successful route in the development of high efficient BiVO₄ photoelectrode for water oxidation is the modification of the BiVO₄-semiconductor nanocomposite surface with OECs. To date, the highest photocurrent density 6.72 mA/cm² at 1.23 V versus RHE was obtained for the CoPi-coated WO₃/BiVO₄ core-shell nanorods [48].

4. Introduction to thermoelectric bismuth-based materials and applications

Thermoelectric (TE) materials are used in appliances such as heat pumps and power generators [59–63]. TE devices offer unique features of low environmental impact, no moving parts, quiet operation, and high reliability. The performance of TE materials is determined by a dimensionless figure of merit, $ZT = \alpha^2 \sigma T / \kappa$, in which α , σ , T , and κ are the Seebeck coefficient, the electrical conductivity, absolute temperature, and the thermal conductivity, respectively. A TE material must exhibit a high power factor ($PF = \alpha^2 \sigma$) and low thermal conductivity (κ) to achieve a high ZT value. However, it is challenging for enhancing the ZT value due to the coupling among the TE parameters [62]: the relationship between α and the carrier concentration n (expressed by $|\alpha| \sim n^{-2/3}$ approximately [60]) limits the increase of the PF ($= \alpha^2 \sigma$), while the proportional relationship between electrical conductivity and electronic thermal conductivity (the Wiedemann-Franz law) restricts the enhancement of the σ / κ ratio.

Bismuth (Bi)-based chalcogenide narrow-bandgap semiconductors such as Bi₂Te₃, Bi₂Se₃, Sb₂Te₃, Bi₂(Te_xSe_{1-x})₃, and (Bi_xSb_{1-x})₂Te₃ are of high interest [64–69]. They have been widely exploited for Peltier coolers and thermoelectric generators at low temperature regime ($\leq 150^\circ\text{C}$) [70, 71]. Thanks to the extensive phonon scattering at grain boundaries, nanocrystalline and nanostructured Bi-based chalcogenide thin films have achieved reduced thermal conductivity [72–77]. However, the lattice imperfections and grain-boundary defects impair the electrical transport properties of the films [72], which call for further investigations to improve PF or the electronic part of ZT. Currently, enhancing the PF of Bi-based thin films is challenging due to not only the coupling among TE material properties [60] but also the tendency of forming nonstoichiometric films at elevated substrate temperatures (T_s) [78]. Numerous charge carriers arising from vacancy defects of volatile elements can constrain the enhancement of $|\alpha|$; however, low carrier concentrations can suppress electrical conductivity if carrier mobility (μ) is poor.

The crystal structures of Bi₂Se₃ and Bi₂Te₃ are usually described by a hexagonal cell that consists of 15 layers of atoms stacking along the *c*-axis with a sequence shown below [60], as shown in **Figure 6**. ... Se⁽¹⁾–Bi–Se⁽²⁾–Bi–Se⁽¹⁾ ... Se⁽¹⁾–Bi–Se⁽²⁾–Bi–Se⁽¹⁾ ... Se⁽¹⁾–Bi–Se⁽²⁾–Bi–Se⁽¹⁾ ... and ... Te⁽¹⁾–Bi–Te⁽²⁾–Bi–Te⁽¹⁾ ... Te⁽¹⁾–Bi–Te⁽²⁾–Bi–Te⁽¹⁾ ... Te⁽¹⁾–Bi–Te⁽²⁾–Bi–Te⁽¹⁾ ... The superscripts refer to two different types of bonding for Se or Te atoms. The five-atomic-layer thick lamellae of –(Se⁽¹⁾–Bi–Se⁽²⁾–Bi–Se⁽¹⁾)– or –(Te⁽¹⁾–Bi–Te⁽²⁾–Bi–Te⁽¹⁾)– is called quintuple layers, QLs. The Se⁽¹⁾... Se⁽¹⁾ or Te⁽¹⁾... Te⁽¹⁾ refers to van der Waals force between Se and Te atoms, whereas the Se⁽¹⁾–Bi and Bi–Se⁽²⁾ or Te⁽¹⁾–Bi and Bi–Te⁽²⁾ are ionic-covalent bonds. This weak binding between the Se⁽¹⁾ – Se⁽¹⁾ and Te⁽¹⁾... Te⁽¹⁾ accounts for the easy cleavage of these materials perpendicular to the *c*-axis and the anisotropic thermal and electrical transport properties. For example, the thermal conductivity along the *c*-axis direction is $\sim 0.7 \text{ W m}^{-1} \text{ K}^{-1}$, while it is $\sim 1.5 \text{ W m}^{-1} \text{ K}^{-1}$ for the plane perpendicular to the *c*-axis [79].

Thin-film technology is advantageous for obtaining nanocrystalline and nanostructured materials by adjusting deposition conditions and subsequent thermal treatments. The extensive phonon scattering at grain boundaries in the nanostructures causes a large reduction in thermal conductivity while maintaining reasonable electrical conductivity, leading to enhanced ZT. Among physical vapor deposition techniques, PLD offers a great versatility in the fabrication of films with multielement stoichiometry and with a variety of structures, from amorphous or nanostructured to polycrystalline or even epitaxial [66–68, 76, 77, 80, 81]. Thin-film TE devices offer some distinctive advantages.

First, a thin-film device has the natural advantage of a small volume (thickness of $\leq 10 \mu\text{m}$, length and width of $\sim 100 \mu\text{m}$) as compared to size of millimeters for a bulk TE couple. As a result, thin-film TE cooling can be integrated into microelectronic systems (**Figure 7a**). In principle, the bulk device can be scaled down to micro sizes; however, fabrication processes to do so are difficult.

Second, thin-film devices have a much shorter response time than bulk devices, as shown in **Figure 7c** [59]. The thin-film device achieves the steady state in $15 \mu\text{s}$, while the bulk device requires 0.35 s [59]. This is a result of the response time associated with the transport of heat through the thin film (micrometers) rather than through the millimeters associated with bulk devices.

Third, the thin-film device has the ability to handle much larger density of heat pumping power than does the bulk device. Typically, bulk devices are working with pumping power

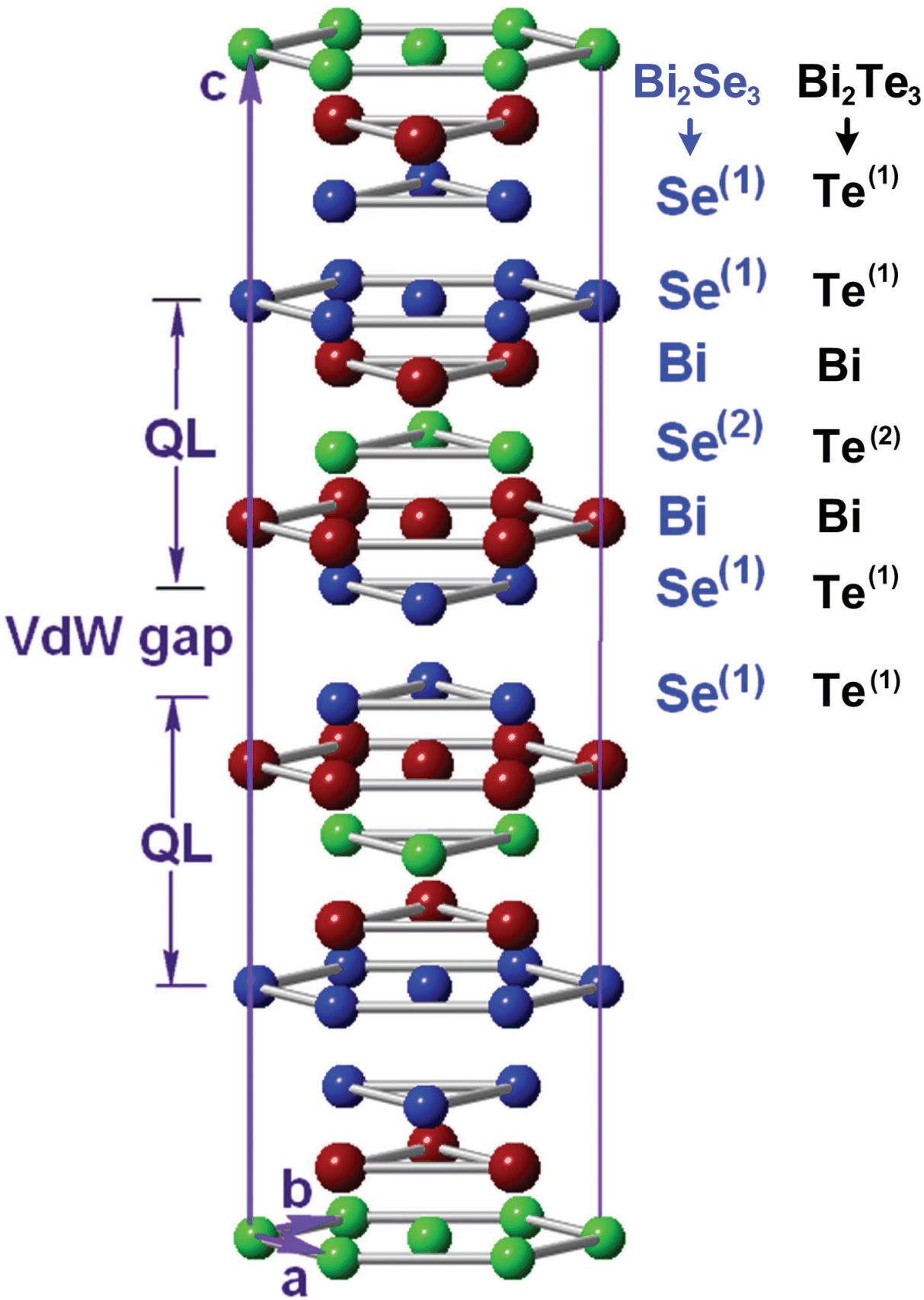


Figure 6. The hexagonal structures of one unit cell of Bi_2Se_3 and Bi_2Te_3 .

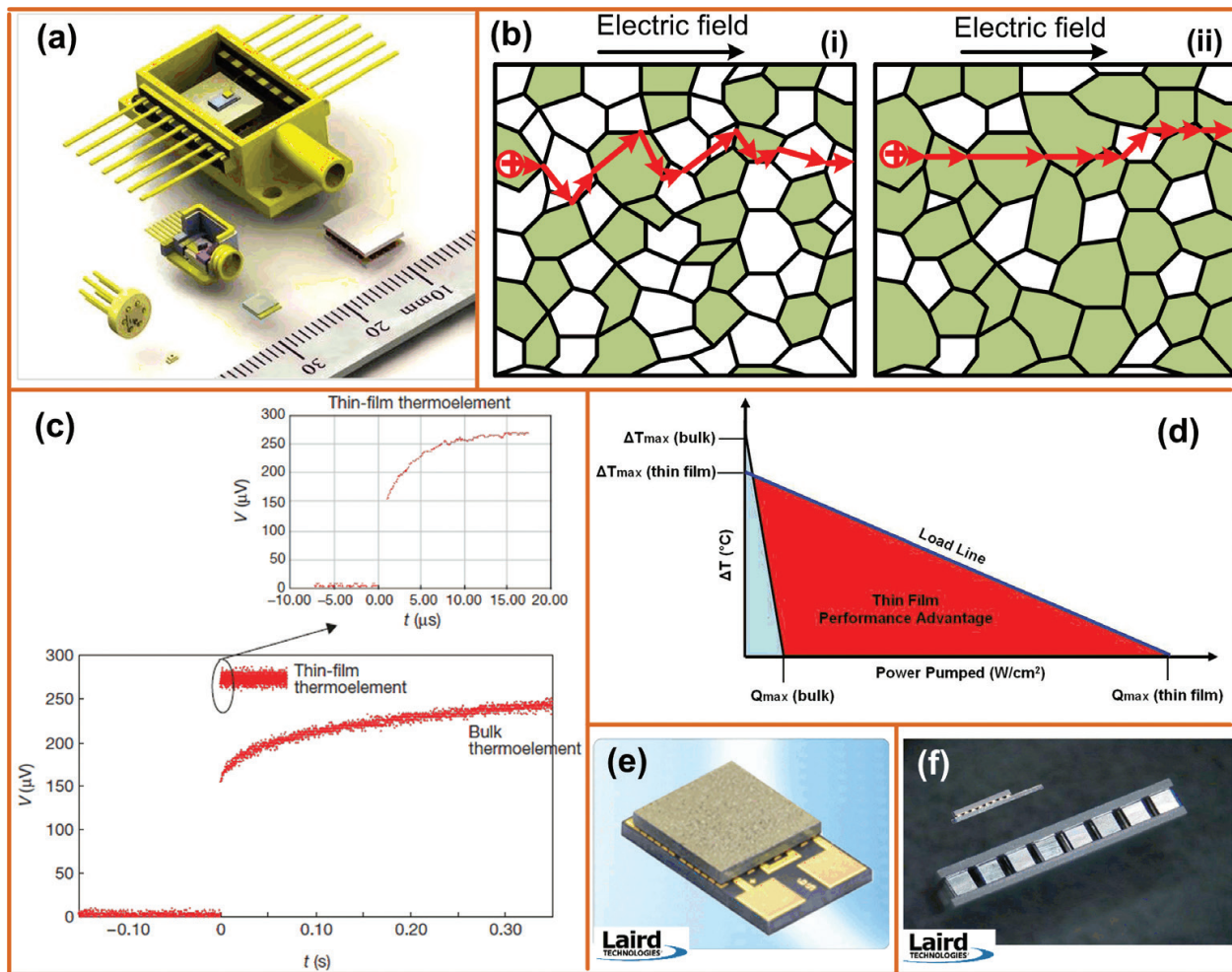


Figure 7. (a) An example for optoelectronics of the continuing reduction in package size. (b) A schematic of grain-boundary scattering for thin-film materials with (i) disoriented-small grains and (ii) highly oriented large grains. (c) The comparison of thermal/cooling time response of thin-film ($\sim 5 \mu\text{m}$) superlattice device and a bulk device [59]. (d) Thermoelectric module performance chart which presents the temperature drop ΔT versus pumping power [83]. (e) A commercial thin-film TE module. (f) Size comparison between a thin-film TE device and bulk TE device [83].

density lower than $10 \text{ W}/\text{cm}^2$; however, the pumping power density in a thin-film device is on the order of hundreds of W/cm^2 [82]. **Figure 7d** illustrates a comparison performance chart between thin-film and bulk TE modules, in which the load line represents the temperature difference (ΔT) between the top and bottom substrate and possible pumping power density (Q) for a given drive current of a TE module [83]. At the maximum drive current for a TE module, the load line is determined by the maximum power density (Q_{max}) and the ΔT_{max} . For a commercial example, under a given drive current, an eTECTM Series thin-film TE module (Laird technology) possesses a larger pumping power up to ten times (**Figure 7e**) and a comparable maximum temperature difference ΔT_{max} than the conventional bulk TE modules [83].

Fourth, the granular structure-morphology of thin films increases the grain-boundary scattering which is helpful for suppressing κ and enhanced ZT values. **Figure 7b** represents the roles of grain orientation and grain size in carrier mobility. The grains with the same colors illustrate that they have the same/similar orientations. The grain-boundary scattering in

Figure 7b(i) will be greater than that of the **Figure 7b(ii)** case because of its smaller grain size and the greater grain disorientation. The effective mobility is given by [84]

$$\mu_s = \frac{Lq}{\sqrt{2\pi m^* kT}} \exp\left(-\frac{\phi_b}{kT}\right) \quad (1)$$

where q is the carrier charge, m^* is the effective mass, k is the Boltzmann constant, T is the temperature, and ϕ_b is the grain-boundary potential barrier in the depletion region. In polycrystalline silicon, the potential barrier height is approximately twice as high at random boundaries as at low-energy coincidence boundaries.

5. Thermoelectric properties of nanocrystalline and nanostructured Bi_2Te_3 -based thin films

Thermoelectric Bi_2Te_3 -based materials have played a dominant role in the field of thermoelectrics. The traditional cooling materials are alloys of Bi_2Te_3 with Sb_2Te_3 (such as $\text{Bi}_{0.5}\text{Sb}_{1.5}\text{Te}_3$; p-type) and of Bi_2Te_3 with Bi_2Se_3 (such as $\text{Bi}_2\text{Te}_{2.7}\text{Se}_{0.3}$; n-type), with a ZT at room temperature approximately equal to one [63]. Recently, nanocrystalline and nanostructured Bi_2Te_3 -based thin films have recently attracted great interests because of their superior TE performance [72–77, 80, 81, 85, 86]. The PF of Bi_2Te_3 films was $8.8 \mu\text{Wcm}^{-1} \text{K}^{-2}$ for an (015)-oriented film with layered-hexagonal morphology [85] and $33.7 \mu\text{Wcm}^{-1} \text{K}^{-2}$ for a highly (001)-oriented layered film [86]. Furthermore, the hexagonal- Bi_2Te_3 film grown using MBE obtained a PF of $27 \mu\text{Wcm}^{-1} \text{K}^{-2}$ [87], and the smooth-epitaxial- Bi_2Te_3 film prepared by co-evaporation achieved a PF of $39.9 \mu\text{Wcm}^{-1} \text{K}^{-2}$ [88].

Despite fewer studies performed on thermoelectric Bi_2Se_3 as compared to Bi_2Te_3 , a considerable amount of recent efforts to enhance TE performance has been devoted to the synthesis of Bi_2Se_3 nanostructures such as hexagonal flakes (PF $\approx 0.28 \mu\text{Wcm}^{-1} \text{K}^{-2}$) [89] and nanoflakes (PF $\approx 0.97 \mu\text{Wcm}^{-1} \text{K}^{-2}$) [90], using the solvo-thermal method and chemical bath deposition, respectively. Moreover, the Bi_2Se_3 film grown by metal organic-chemical vapor deposition has reached a PF = $5.8 \mu\text{Wcm}^{-1} \text{K}^{-2}$ [91]. In PLD, tightly controlling substrate temperatures (T_s)

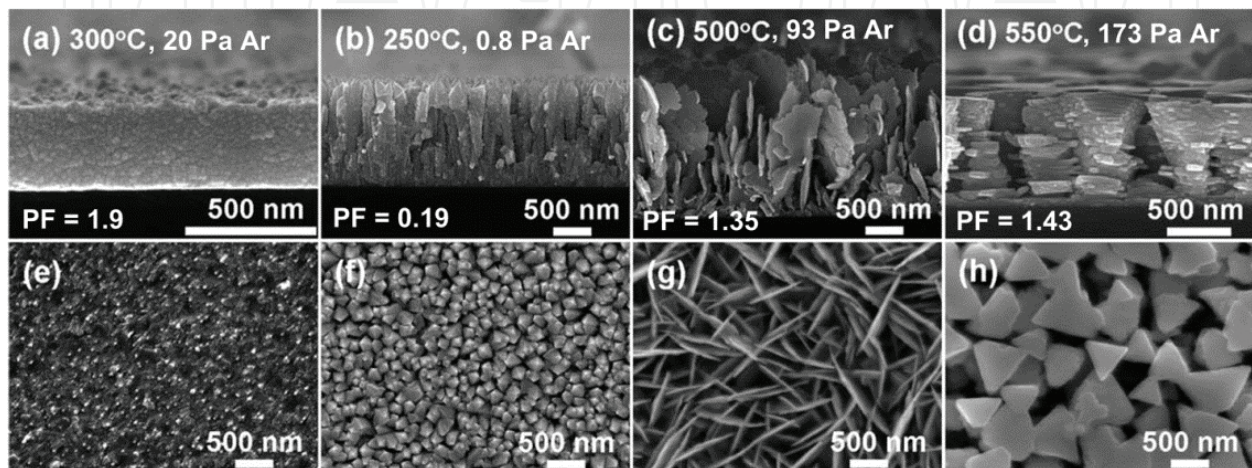


Figure 8. The morphology and power factor (PF, unit $\mu\text{Wcm}^{-1} \text{K}^{-2}$) of nanostructured Bi_2Te_3 thin films grown by PLD at various substrate temperatures and ambient pressures, reported by Chang and Chen [77].

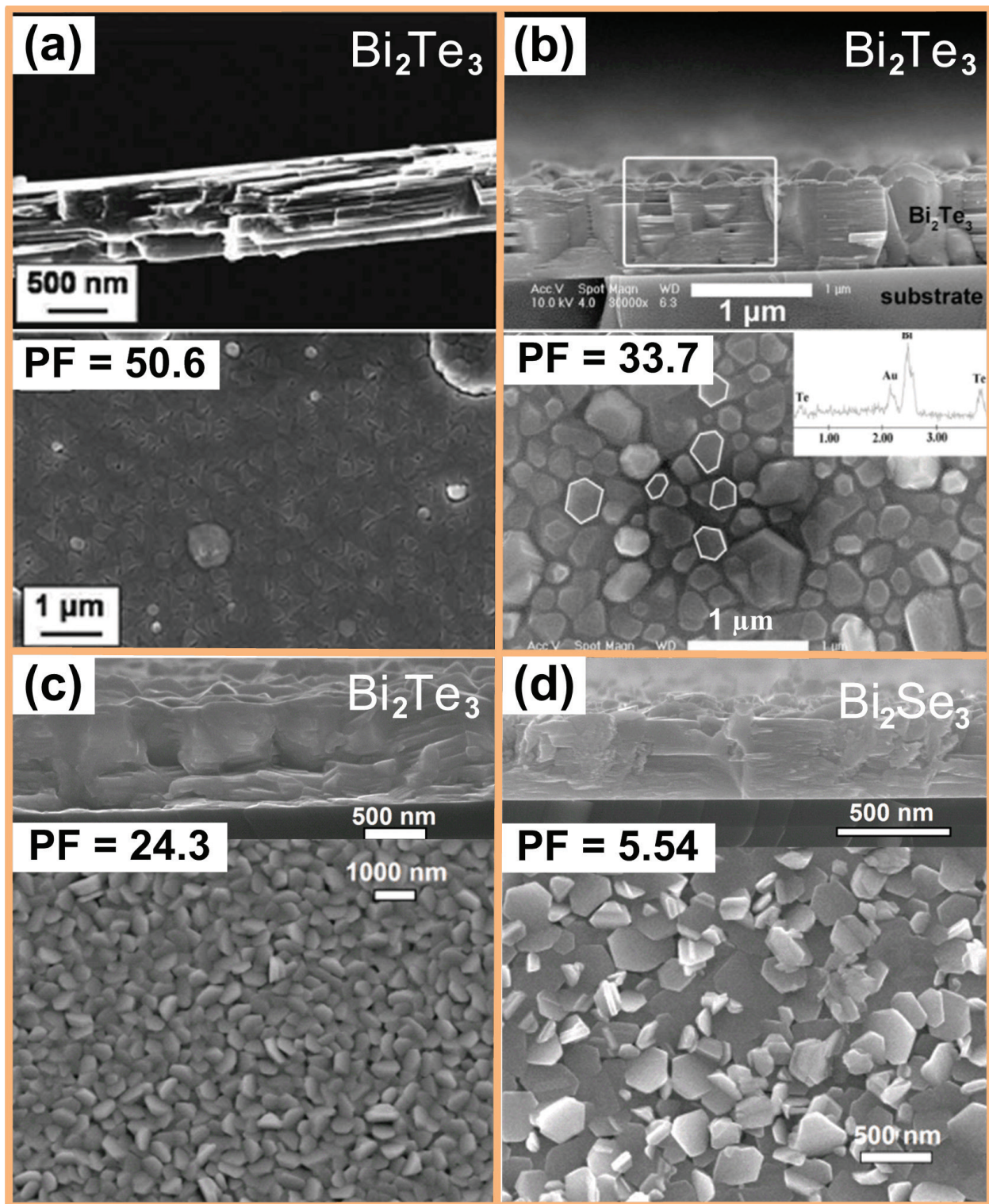


Figure 9. The morphology and power factor (PF, unit $\mu\text{Wcm}^{-1} \text{K}^{-2}$) of the optimal Bi_2Te_3 and Bi_2Se_3 thin films with layered structures grown by PLD, reported in Refs. [66, 67, 80, 86].

and ambient pressures enable the morphologies and compositions of films to be manipulated extensively, which offer a new method for enhancing the TE properties of films. For example, self-assembled Bi_2Te_3 films featuring well-aligned zero- to three-dimensional nanoblocks have been fabricated (Figure 8), but the room temperature PFs of these films remain low ($\leq 1.9 \mu\text{Wcm}^{-1} \text{K}^{-2}$) due to the low electrical conductivity of the voided structures [77].

By contrast, the Bi_2Te_3 -based thin films with compact and/or layered structures possess the high electrical conductivities and relatively high Seebeck values if the films obtain stoichiometry. For example, A. Li Bassi et al. reported a high PF of $50.6 \mu\text{Wcm}^{-1} \text{K}^{-2}$ for the layered-smooth Bi_2Te_3 films (**Figure 9a**) [80]. Similarly, the Bi_2Te_3 films with layered-hexagonal grain structure exhibited a high PF of $33.7 \mu\text{Wcm}^{-1} \text{K}^{-2}$ (**Figure 9b**) [86]. P.H. Le et al. found that the optimal PF films also present compact-layered structures, namely, $\text{PF} = 24.3 \mu\text{Wcm}^{-1} \text{K}^{-2}$ for the Bi_2Te_3 film (**Figure 9c**) and $\text{PF} = 5.54 \mu\text{Wcm}^{-1} \text{K}^{-2}$ for the hexagonal Bi_2Se_3 film (**Figure 9d**) [66, 67]. Usually, compact or layered structure films obtain high carrier mobility than those with the open/voided nanostructures.

Table 1 summarizes thermal transport properties (at room temperature) of nanocrystalline-nanostructured Bi_2Te_3 -based thin films and bulk materials in the literature [62, 72–76, 87, 92].

Sample, fabrication method	Avg. grain size	κ (W/m K)	σ (S/cm)	α ($\mu\text{V/K}$)	$\text{PF} = \sigma\alpha^2$ ($\mu\text{W/cmK}^2$)	ZT (300 K)	Ref.
$\text{Bi}_2\text{Te}_{2.7}\text{Se}_{0.3}$ nanocrystalline thin film, flash evaporation	60 nm	0.8 (cross-plane)	540	−186.1(in-plane)	18.7(in-plane)	0.7	[72]
Sintered bulk $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ material, hot pressing	30 μm	1.6	930	−177.5	29.3	0.6	
Nanocrystalline bismuth-telluride-based ($\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$) thin film	10 nm	0.61	550	−84.0	3.9	0.19	[73]
	27 nm	0.68	540	−138.1	10.3	0.46	
	60 nm	0.80	540	−186.1	18.7	0.70	
Nanocrystalline Bi-Sb-Te thin film, sputtering	26 nm	0.46	3.3	—	—	—	[75]
	45 nm	0.65	6.7	—	—	—	
	84 nm	0.81	33.3	—	—	—	
Nanocrystalline BiSbTe (8:30:62) thin film, flash evaporation	150 nm	0.6	—	—	—	—	[74]
Single crystal BiSbTe bulk alloys	—	0.75	—	—	—	—	[62]
$\text{Bi}_2\text{Te}_3/\text{Sb}_2\text{Te}_3$ superlattices (period ~5 nm)	—	0.4	—	—	—	—	[93]
$\text{Bi}_2\text{Te}_{3+0.63}$ bulk	—	2.2	1000	−240	58	0.87	[62]
$\text{Bi}_2(\text{Te}_{0.95}\text{Se}_{0.05})_3$ bulk	—	1.59	901	−223	45	0.85	[62]
$\text{Bi}_2\text{Te}_3/\text{Bi}_2(\text{Te}_{0.88}\text{Se}_{0.12})_3$ superlattice film, MBE	80 nm	1.25	639	−204	27	0.60	[87]
Bi_2Te_3 films, laser ablation	—	0.2–0.3	—	—	—	—	[92]
$\text{Bi}_x\text{Sb}_{2-x}\text{Te}_3$ nanolayer film, PLD	190 nm	1.16	2700	95	25	0.65	[76]
$\text{Bi}_x\text{Sb}_{2-x}\text{Te}_3$ nanodisk film, PLD	100 nm	1.00	1100	132	20	0.60	
$\text{Bi}_x\text{Sb}_{2-x}\text{Te}_3$ nanocolumn film, PLD	70 nm	0.93	280	207	12	0.39	

Table 1. Room temperature thermal transport properties of nanocrystalline-nanostructured Bi_2Te_3 -based thin films and bulk materials in the literature, including sample and fabrication method, average grain size, thermal conductivity κ , electrical conductivity σ , Seebeck coefficient α , power factor PF ($= \alpha^2\sigma$), and ZT (at 300 K).

Generally, the thermal conductivity κ value for polycrystalline films is expected to be smaller than that of bulk alloys because of the contribution of grain-boundary scattering [62, 72, 74]. Moreover, the κ of nanocrystalline Bi₂Te₃-based films will further decrease when the grain size of decreases ($\kappa \leq 0.81$ W/mK) [73, 75]. For Bi₂Te₃/Sb₂Te₃ superlattice films, the coherent backscattering of phonon waves at the superlattice interfaces is outlined for the reduction of lattice thermal conductivity, resulting in the low $\kappa \leq 0.4$ W/mK [93].

For PLD Bi₂Te₃-based films, Walachova et al. [92] estimated κ starting from direct ZT measurement with the Harman method and found a value of about 0.2–0.3 W/mK for films with a thickness comparable to our films (>100 nm). Recently, Chang et al. [76] reported the κ between 0.93 and 1.16 W/mK for granular Bi_xSb_{2-x}Te₃ films. The reported κ (at 300 K) of hexagonal flake Bi₂Se₃ was 0.75 W/mK.

6. Conclusion

We report the crystal, electronic structures, optical properties, and PEC activities of BiVO₄-based materials. Morphology engineering, cocatalyst loading, and doping with metal and nonmetal composite structures are the approaches to fabricate high efficiency BiVO₄ photoelectrode for PEC water spitting. In addition, the Bi₂Te₃-based thin films with nanocrystalline and nanostructured morphologies obtain the reduced thermal conductivity, meanwhile the close stoichiometric films with layered structure morphologies exhibit high thermoelectric power factors. BiVO₄-based materials and Bi₂Te₃-based thin films play significant roles for the photoelectrode and thermoelectric applications.

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